

Supporting Information

Modulating Schottky Barrier of MXenes/2D SiC contacts via functional groups and biaxial strain: A First-Principles Study

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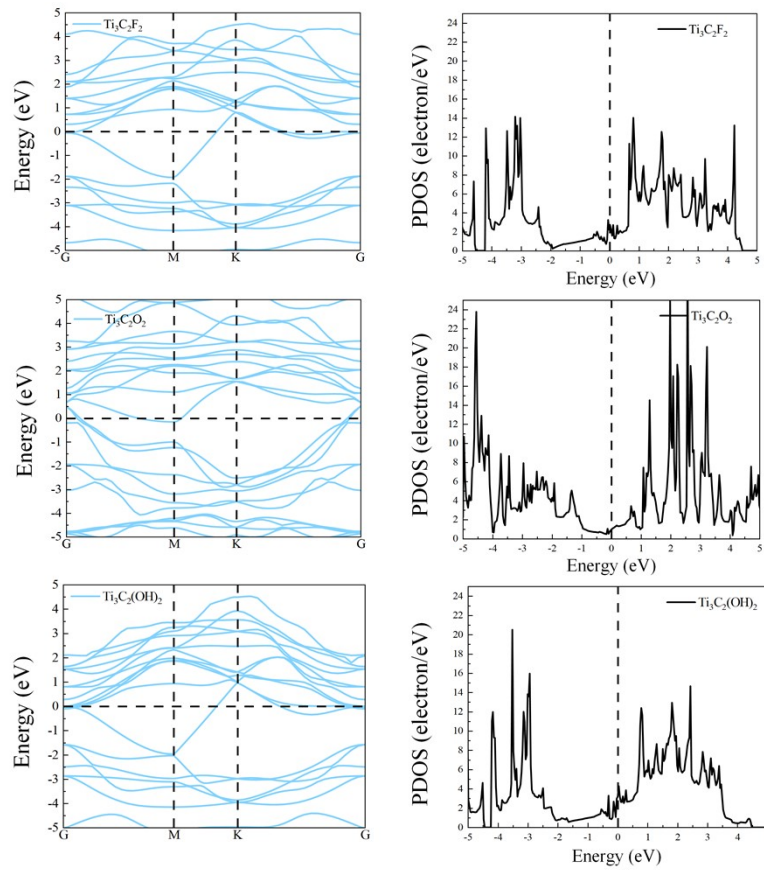


Figure S1. The band structures and PDOS of $\text{Ti}_3\text{C}_2\text{T}_2$. (The E_F is set to zero)

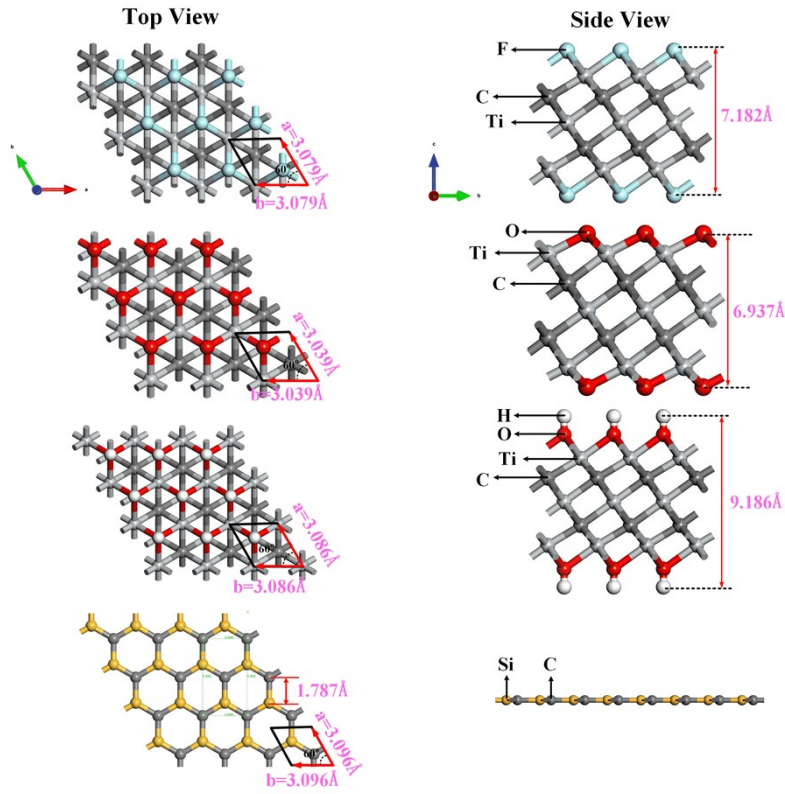


Figure S2. Top and Side views of crystal structures of $\text{Ti}_3\text{C}_2\text{T}_2$ and SiC.

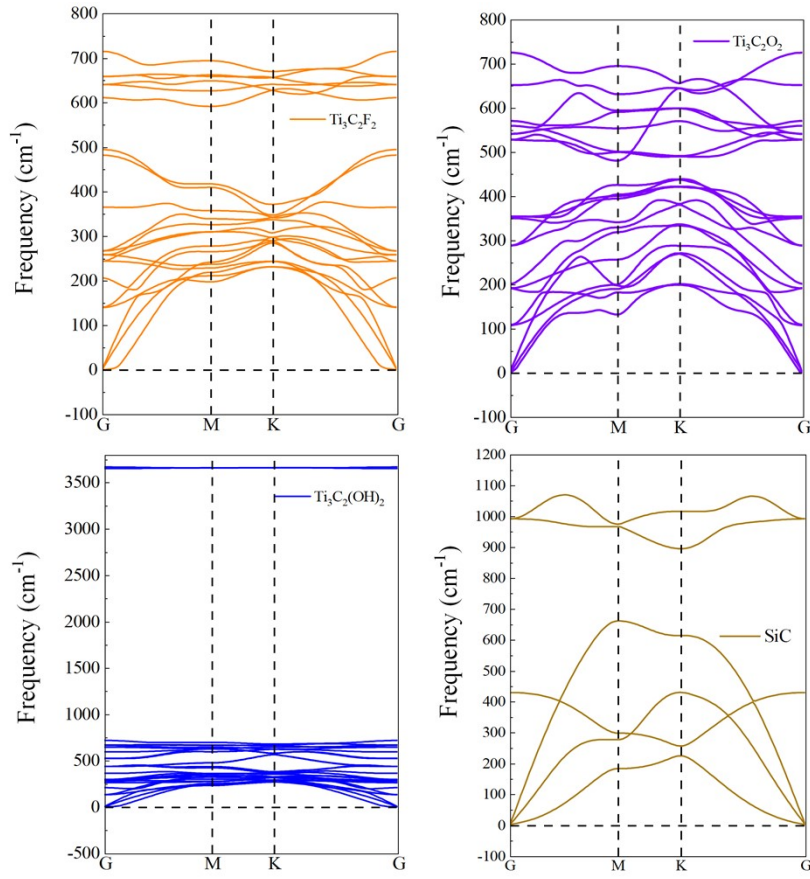


Figure S3. The phonon dispersion spectra of $\text{Ti}_3\text{C}_2\text{T}_2$ and SiC.

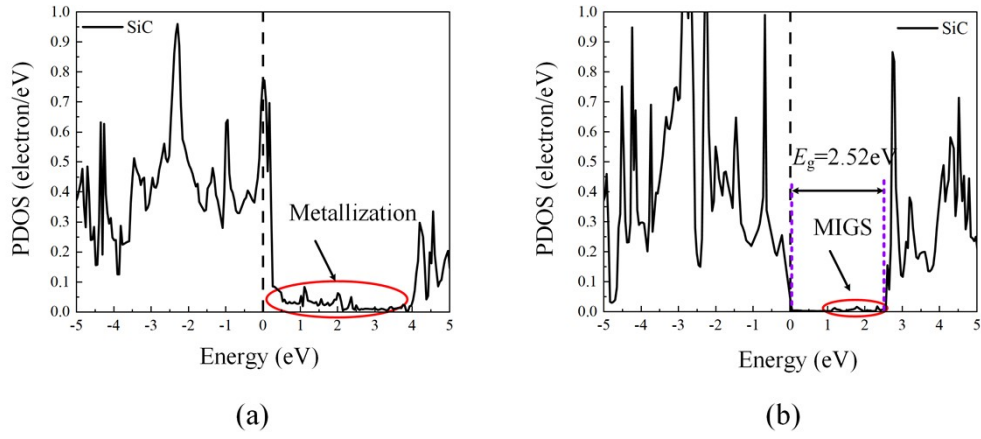


Figure S4. PDOS of SiC in (a) $\text{Ti}_3\text{C}_2\text{O}_2/\text{SiC(A)}$ contact, (b) $\text{Ti}_3\text{C}_2\text{O}_2/\text{SiC(B)}$ contact (The E_F is set to zero).

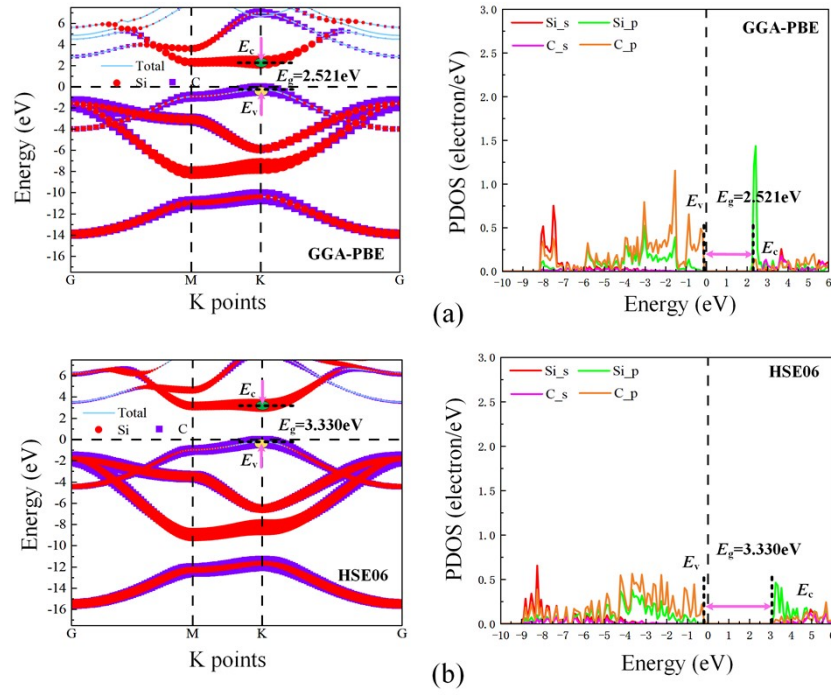


Figure S5. Band structures and PDOS of SiC calculated from (a) PBE and (b) HSE06 functional, respectively. (The E_F is set to zero).